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N-Bridged and H-Bridged Aminoalanes: Single-Crystal X-ray Structure Determinations for the Planar Dimer $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ and the Puckered Four-Membered Ring Compound $(Me_3Si)_2N(Me_2N)Al(\mu-NMe_2)_2Al(H)N(SiMe_3)_2$.

Jerzy F. Janik and Richard L. Wells

Department of Chemistry, Paul M. Gross Chemical Laboratory, Duke University

Durham, NC 27708-0346

and

Arnold L. Rheingold and Ilia A. Guzei

Department of Chemistry, University of Delaware, Newark, DE 19716

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Duke University
Department of Chemistry,
P. M. Gross Chemical Laboratory
Box 90346
Durham, NC 27708-0346

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N-Bridged and H-Bridged Aminoalanes: Single-Crystal X-ray Structure Determinations for the Planar Dimer $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ and the Puckered Four-Membered Ring Compound $(Me_3Si)_2N(Me_2N)Al(\mu-NMe_2)_2Al(H)N(SiMe_3)_2.$

Jerzy F. Janik[‡] and Richard L. Wells*

Department of Chemistry, Paul M. Gross Chemical Laboratory, Duke University

Durham, NC 27708-0346

Arnold L. Rheingold and Ilia A. Guzei

Department of Chemistry, University of Delaware, Newark, DE 19716

Abstract: The known bis(bis(trimethylsilyl)amino)alane {[(Me₃Si)₂N]₂Al(μ -H)}₂ (1) is obtained from disproportionation of the base-stabilized monomeric bis(trimethylsilyl)aminoalane [(Me₃Si)₂NAlH₂]•NMe₃ in refluxing toluene. The single-crystal X-ray structure determination for 1 provides a H-bridged planar dimer with exocyclic N(SiMe₃)₂ groups. The combination of 1 with HNMe₂ in a 1:1 ratio results in competing aminolysis at the Al-H site and transamination at the Al-N(SiMe₃)₂ site of 1, as illustrated by the molecular structure of (Me₃Si)₂N(Me₂N)Al(μ -NMe₂)₂Al(H)N(SiMe₃)₂ (2) which is isolated from this system. The characteristic structural feature of 2 is a puckered {Al-N-Al-N} ring with different ligands on two aluminum atoms.

Keywords: alanes; trimethylsilylamines; disproportionation; transamination; aminolysis; precursors.

^{*} Correspondence to: R. L. Wells

[‡] On leave from the University of Mining and Metallurgy, Krakow, Poland

Introduction

In the solid state, some alane amine adducts show dimeric connectivities [H₃Al•L]₂ (for example, L = NMe₃, la NMe₂CH₂Ph^{1b}) with five-coordinated aluminum atoms and somewhat counterintuitive unsymmetrical Al-H-Al bridges while, on the other hand, others seem to favor a monomeric mode with four-coordinated Al in H₃Al•L (for example, L = N(n-Bu)₃l^c, quinuclidine^{1d}) or five-coordinated Al having a N-Al(H₃)-N bond sequence as in trigonal bipyramidal H₃Al•2NMe₃.le This span of bonding preferences in the alane adducts is generally interpreted as a manifestation of the ligand's steric hindrance and is not an exclusive property of amine Lewis bases. The latter is illustrated by examples of the Al-H-Al bridged dimer [H₃Al•THF]₂ and trigonal bipyramidal H₃Al•2THF with an O-Al(H₃)-O axis.lf Even more complex bonding environments are encountered in some polymeric structures containing AlH₃ units.lg Finally, ionic bonding is displayed by rare species of the type (H₂AlL)+(AlH₄)- where L is a tri- or tetradentate amine ligand.lh The progress in the chemistry of Lewis base adducts of alane and gallane has recently been reviewed.li

The aminoalanes, {H_nAl(NR₂)_{3-n}} (n = 0, 1, 2), appear to exhibit similar diversity of bonding as outlined above for alane amine adducts but relatively shorter Al-N bond lengths in the former make the steric factor play a more obvious role. For example, the dimethylaminoalane, (H₂AlNMe₂)₃, is a N-bridged trimer in solution^{2a} and in the solid state^{2b} but both bis(dimethylamino)alane, [HAl(NMe₂)₂]₂,^{2c} and tris(dimethylamino)alane, [Al(NMe₂)₃]₂,^{2d}, e are N-bridged dimers. Even larger NR₂ groups may result in N-bridged dimeric cores such as found in 2,6-dimethylpiperidinoalane, [H₂Al(dmp)]₂.^{2f} A further increase of the bulkiness of the piperidino ligand, in the absence of NMe₃ as in the reaction between LiAlH₄ with (tmpH)•HCl, yields a postulated H-bridged trimer 2,2,6,6-tetramethylpiperidinoalane, [H₂Al(tmp)]₃, or, even in the presence of NMe₃ in the reaction between H₃Al•NMe₃ with 2 equivalents of tmpH, gives the authenticated H-bridged dimer

bis(2,2,6,6-tetramethylpiperidino)alane, [HAl(tmp)₂]₂.^{2f} On the other hand, an extreme bulkiness of N(SiMe₃)₂ coupled with a latent N-basicity in this group is thought to be responsible for the kinetic stabilization of the unassociated Al[N(SiMe₃)₂]₃.^{2g}

In addition to the formation of the N- or H-bridged aminoalanes, stabilization of the aminoalane unit by an available Lewis base may sometimes also be favorable. In systems utilizing the convenient form of alane, H₃Al•NMe₃, trimethylamine as a potent Lewis base is found in a few cases to play that role. It was originally reported that the monomeric aminoalane, stabilized by coordination of NMe₃ at the Al-site, [H₂AlN(SiMe₃)₂]•NMe₃, was formed from the reaction between H₃Al•NMe₃ and HN(SiMe₃)₂.³ This finding was later confirmed in a parallel study, which additionally provided a structural proof for a related [H(Cl)AlN(SiMe₃)₂]•NMe₃.^{4a} Further, a 1:1 ratio reaction between H₃Al•NMe₃ and tmpH afforded [H₂Al(tmp)]•NMe₃,^{4b} which can be compared with the previously discussed H-bridged trimer [H₂Al(tmp)]₃^{2f} obtained in the absence of trimethylamine. One should be aware that this kind of adduct stabilization extends into other group 3–5 systems and, for example, is also found in the pnictinoalanes [H₂AlEMes₂]•NMe₃ (E = P, As)^{4c} and [H₂AlAs(SiMe₃)₂]•NMe₃.^{4d}

The original reports by Paine and coworkers on the preparation of [H₂AlN(SiMe₃)₂]•NMe₃³ indicated that thermal decomposition of this compound resulted in the formation of new bis(bis(trimethylsilyl)amino)alane {[(Me₃Si)₂N]₂Al(μ-H)}_n of an undetermined degree of oligomerization; some analytical evidence, however, supported the presence of Al-H-Al bridges in this product.^{3b} This was contrary to what the parallel report by Raston and coworkers claimed about the thermal behavior of [H₂AlN(SiMe₃)₂]•NMe₃,^{4a} namely, decomposition to elemental aluminum presumably along a reductive coupling pathway with dihydrogen evolution and, here, additionally, with concurrent release of NMe₃. In this regard, one has to be aware that reductive coupling is not the only thermally induced decomposition pathway for aminoalanes and it has long been known that their ligand disproportionation chemistry is of equal importance.^{2c, 5}

Herein, we confirm the originally reported disproportionation of $[H_2AlN(SiMe_3)_2]$ -NMe3 and describe the single-crystal X-ray diffraction study for the resulting H-bridged dimer, bis(bis(trimethylsilyl)amino)alane $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ (1). We also outline the reaction of 1 with HNMe2 and the isolation of an unsymmetrically substituted product $(Me_3Si)_2N(Me_2N)Al(\mu-NMe_2)_2Al(H)N(SiMe_3)_2$ (2) for which a single-crystal structure is presented.

Experimental

General techniques. All experiments were carried out using standard vacuum/Schlenk techniques. Solvents were dried and distilled from Na benzophenone ketyl or Na/K alloy HNMe2 was obtained from Aldrich and used as received. prior to use. [H₂AlN(SiMe₃)₂]•NMe₃ and {[(Me₃Si)₂N]₂Al(μ -H)}₂ were prepared by the literature methods;3b the synthesis and characterization of the latter is also described in more detail below. ¹H and ¹³C{¹H} NMR spectra were acquired on the Varian Unity 400 spectrometer at 25 °C from toluene-d₈ solutions and referenced vs SiMe₄ by generally accepted methods. Mass spectra were collected on a JEOL JMS-SX 102A spectrometer operating in the EI mode at 20 eV. IR spectra of solids and oily products were acquired using KBr pellets and NaCl plates, respectively, on a BOMEM Michelson MB-100 FT-IR spectrometer. A calibrated manifold was used for volume estimations of reaction gases. Melting behavior (uncorrected) was determined with a Thomas-Hoover Uni-melt apparatus for samples flame-sealed in glass capillaries. Single-crystal X-ray diffraction studies for 1 and 2 were performed at the University of Delaware, Department of Chemistry and Biochemistry, Newark, DE, on a Siemens P4/CCD diffractometer, using Mo K_α radiation $(\lambda = 0.71073 \text{ Å})$. All calculations were carried out with the help of SHELXTL 5.03 programs; 6 the structures were solved by direct methods.

A sample of $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ (2). Preparation of [H₂AlN(SiMe₃)₂]•NMe₃, 1.24 g or 5.0 mmol, was dissolved in about 10-15 mL of toluene, stirred, and refluxed overnight under nitrogen. Typically, elemental aluminum precipitated on the sides of reaction flask in the form of agglomerates but, sometimes, aluminum would form as a colloidal suspension. The mixture was concentrated by evacuation to about 5-10 mL and refluxed for additional 24 hours. Subsequently, it was filtered, the volatiles evacuated from the filtrate, and the resulting residue dissolved in a few mL of hexane. The concentrated hexane solution after storage at -30 °C afforded abundant colorless crystals of 1, 0.48g or 55% yield based on equation 1 (vide infra). More crystalline product could be recovered from the solution by further concentrating and repeating the low temperature crystallization. M.p. 95-97 °C. ¹H NMR: δ 0.34 (36H; SiMe₃), 4.4 (1H, br; AlH). ${}^{13}C\{{}^{1}H\}$ NMR: δ 6.0 (SiMe₃). MS: m/e (intensity) (ion): peak clusters around: 695 (1) ($\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2 - H$ or M - H), 667 (1) (M -2Me + H), 596 (1) (M - SiMe₃ + 3H), 552 (2) (M - 2SiMe₃ + 2H), 536 (2) (M - $N(SiMe_3)_2$, 492 (3) (M – $N(SiMe_3)_2$ – 3Me + H), 461 (2) (M – $N(SiMe_3)_2$ – 5Me) 421 (5) $(M - N(SiMe_3)_2 - SiMe_3 - 3Me + 3H)$, 347 (3) $([(Me_3Si)_2N]_2AlH - H \text{ or } M^* - H)$, 331 (2) $(M^* - Me - 2H)$, 300 (2) $(M^* - 3Me - 3H)$, 275 (3) $(M^* - SiMe_3)$, 202 (3) $(M^* - SiMe_3)$ $-2SiMe_3$), 161 (20) (HN(SiMe₃)₂), 146 (100) (HN(SiMe₃)₂ - Me), 130 (10) (HN(SiMe₃)₂ – 2Me – H), 74 (9) (HSiMe₃). IR (KBr pellet/Nujol mull): v(Al–H) range, 1882/1880 cm⁻¹. We note that these Al-H stretching frequencies significantly differ from that of a weak band at 1790 cm⁻¹ originally reported for 1.3b In the present study, the medium intensity band at about 1880 cm⁻¹ was reproducible, but its intensity was decreasing fast in the course of measurements due to deterioration of the sample. At this point, we are inclined to think that the band reported earlier might have been recorded for a significantly decayed sample.

Reactions of $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ with HNMe₂. Isolation of $(Me_3Si)_2N(Me_2N)Al(\mu-NMe_2)_2Al(H)N(SiMe_3)_2$ (2). 0.10 g of 1 (0.14 mmol) was dissolved in about 10 mL of toluene and the reaction flask was freeze-pump-thawed three times. Onto this, using a calibrated vacuum line, 0.29 mmol of HNMe₂ was deposited at -78 °C. The mixture was stirred at room temperature overnight and noncondensables, H₂, were measured, 0.04 mmol. The solution was then stored for a few days at -30 °C. At the end of this period, the volatiles were removed yielding an oil/solid product. IR (neat): weak to medium band in the v(N-H) range at 3310 cm⁻¹; medium band in the v(Al-H) range at 1833 cm⁻¹. A toluene-d₈ NMR sample of this product was run immediately, one day, two weeks, and seven weeks after preparation. Immediately: ¹H NMR (intensity) (group assignment): SiMe₃ region: δ 0.08 (9) (HN(SiMe₃)₂), 0.27 (23), 0.31 (24), 0.33 (100); NMe₂ region: δ 1.88 (9), 1.89 (9), and several small intensity peaks (< 1) in this region at 2.29, 2.32, 2.41, 2.42, 2.51, 2.60, 2.76; AlH region: δ 4.0 (very broad), 4.51. ${}^{13}C{}^{1}H$ NMR (intensity) (group assignment): SiMe₃ region: δ 2.6 (7) (HN(SiMe₃)₂), 5.0 (3), 6.2 (100), 6.5 (16), 6.8 (4); NMe₂ region: δ 37.9 (24), 40.4 (1), 41.6 (2), 42.0 (3), 43.2 (2), 43.5 (7). One day after: ¹H NMR (intensity) (group assignment): SiMe₃ region: δ 0.08 (100) (HN(SiMe₃)₂), 0.27 (50), 0.31 (80), 0.33 (35); NMe₂ region: δ 1.88 (1), 1.89 (1), 2.42 (15), 2.51 (1), 2.60 (8), 2.76 (2); no unequivocally measurable broad feature in the AlH region except for the sharp resonance at δ 4.51. ¹³C{¹H} NMR (intensity) (group assignment): SiMe₃ region: δ 2.6 (90) $(HN(SiMe_3)_2)$, 4.9 (55), 6.2 (70), 6.5 (100), 6.8 (14); NMe₂ region: δ 37.9 (13), 40.4 (15), 41.6 (5), 42.0 (10), 43.2 (10), 43.5 (70). Two weeks after: ¹H NMR (intensity) (group assignment): SiMe₃ region: δ 0.08 (100) (HN(SiMe₃)₂), 0.27 (55), 0.31 (83), 0.33 (6); NMe₂ region: δ 1.88 (1), 1.89 (1), 2.42 (16), 2.52 (3), 2.60 (8), 2.76 (4); AlH region: δ 4.1 (broad), 4.51. ¹³C{¹H} NMR (intensity) (group assignment): SiMe₃ region: δ 2.6 (83) (HN(SiMe₃)₂), 4.9 (63), 6.2 (35), 6.5 (100), 6.8 (32); NMe₂ region: δ 37.9 (1), 40.4 (20), 41.6 (16), 42.0 (19), 43.2 (17), 43.5 (65). Seven weeks after: the NMR spectra were identical to those obtained after two weeks. The oily/solid product was redissolved in a small amount of toluene and, subsequently, volatiles were allowed to evaporate at -30 °C in the course of several days. After almost complete removal of volatiles, a small quantity of a colorless crystalline product was isolated. A single-crystal X-ray structure determination provided (Me₃Si)₂N(Me₂N)Al(μ -NMe₂)₂Al(H)N(SiMe₃)₂ (2). ¹H NMR for a freshly prepared sample (intensity) (group assignment): SiMe₃ region: 0.281 (85), 0.284 (100), 0.29 (63), 0.30 (77), 0.31 (52), 0.32 (71), 0.33 (58); NMe₂ region: δ 2.42 (14), 2.52 (12), 2.66 (25), 2.77 (19), 2.78 (16); AlH region: no discernible feature between δ 3.0–5.0. This sample was also run two days after preparation and showed an even more complex spectrum indicating continuing changes in the solution. IR (KBr pellet): v(Al-H) range, medium to strong band at 1860 cm⁻¹.

Structural determinations for 1 and 2.

Specimens of 1 were obtained in the form of thin colorless needles from recrystallization in toluene at –30 °C and mounted in capillaries prior to determination. The systematic absences in the diffraction data were consistent with monoclinic space groups P2₁/m and P2₁ but only the latter yielded computationally stable results and refinement. The structure was solved using direct methods, completed by subsequent difference Fourier syntheses and refined by full-matrix least-square procedures. All non-hydrogen atoms were refined with anisotropic displacement coefficients. All C-hydrogen atoms were treated as idealized contributions. The Al-hydrogen atoms were located from the difference map and were refined with fixed thermal parameters and fixed Al-H distances, 1.727(1) Å. The geometry of the {Al-H-Al-H} ring was not constrained. There are two symmetry independent, but chemically similar, molecules in the asymmetric unit and the thermal ellipsoid diagram of molecule 1 is shown in Figure 1. The thermal ellipsoid diagram of molecule 2 is available in the Supporting Information. Specimens of 2 were obtained as blocky colorless crystals from slow evaporation of toluene at –30 °C and mounted in

capillaries prior to determination. The data were consistent with the monoclinic space group P2₁/n. The structure was solved using direct methods, completed by subsequent difference Fourier syntheses and refined by full-matrix least-square procedures. Semi-empirical absorption corrections were not required because there was less than 10% variation in the integrated Ψ-scan intensity data. The Si-N distances were restrained to an average N-Si distance of 1.74 Å. All non-hydrogen atoms were refined with anisotropic displacement coefficients. The hydrogen atom on Al(1) was placed in an idealized position with the fixed Al-H distance of 1.50 Å. All other hydrogen atoms were treated as idealized contributions. The residuals for 2 are rather high due to marginal quality of the specimen. However, the metric parameters and their esd's around aluminum atoms appear to be of acceptable quality. The thermal ellipsoid diagram of 2 is shown in Figure 2. Details of the data collection for 1 and 2 are summarized in Table 1, and Table 2 shows selected bond distances and angles.

Results and discussion

Bis(bis(trimethylsilyl)amino)alane $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ (1) was obtained from disproportionation of the based-stabilized monomeric aminoalane $[H_2AlN(SiMe_3)_2]$ -NMe₃ as described by idealized equation 1.3b

The anticipated formation of the alane trimethylamine byproduct, H₃Al•NMe₃, would have been associated with its decomposition under toluene reflux conditions and precipitation of elemental aluminum,⁷ which was indeed observed. We found this disproportionation

reaction to be crucially dependent on the substrate's concentration. For example, dilute toluene solutions did not show signs of the precipitation of elemental aluminum even after a several day-long reflux. On the other hand, appropriately concentrated solutions appeared to react as above in the course of several hours while intermediate removal of some toluene by evacuation accelerated the reaction's progress and resulted in increased yields. The isolation of 1, after filtering out aluminum, was accomplished by low temperature recrystallization from hexane in which it was much less soluble than was unreacted [H₂AlN(SiMe₃)₂]•NMe₃.

The characterization data acquired for 1 in this study were consistent with its chemical make-up as originally reported. Especially, the mass spectrum showed the parent ion for the dimer and other logically derived fragmentation ions. A few higher than dimer m/e fragments of extremely low intensity (< 1%) were also detected. This indicated that the dimeric association via H-bridges generally survived the heated probe and electron impact conditions in the MS experiment. The ¹H and ¹³C{¹H} NMR spectra were in agreement with the original NMR data for 1 and, based on their simplicity, supported a symmetrical environment for the N(SiMe₃)₂ groups while excluding a possible rigid, N-bonded structure.

The crystallographic determination for 1 provided two symmetry independent, but chemically similar, molecules in the asymmetric unit. Figure 1 shows the structure of one of the molecules. The molecule of 1 is a H-bridged dimer which is structurally very similar although not isomorphous with the H-bridged dimer bis(2,2,6,6-tetramethylpiperidino)alane, [HAl(tmp)₂]₂,^{2f} or related F-bridged dimer [(tmp)₂AlF]₂.^{8a} For example, the wide average N-Al-N angle in 1, 124.6°, can be compared with the same angles in [HAl(tmp)₂]₂, 126.9(1)° and [(tmp)₂AlF]₂, 128.6(1)°, and they all may reflect similar steric demands of the amino groups in these compounds. The environment around each N-atom in 1 is planar (2Si, N, and Al connected atoms lie in the same plane; sum of relevant angles is close to 360°) and, although it is tempting to associate this

property with a mostly $d_{\Pi}(Si)-p_{\Pi}(N)$ interaction in the N(SiMe₃)₂ ligand, a planar environment appears to exist in the similar {2C, N, Al} fragment in [HAl(tmp)₂]₂ which is lacking such an interaction.

The average Al-N bond length in 1, 1.824 Å, belongs to short distances of this type and its magnitude seems to be a consequence of a tetracoordinate Al atom bonded to a sterically congested tricoordinate N atom. This is strikingly supported by comparison with the Al-N distances in the relevant cases of the previously discussed [HAl(tmp)₂]₂, 1.835(3) Å, and [(tmp)₂AlF]₂, 1.832(2) Å, as well as of [H(Cl)AlN(SiMe₃)₂]•NMe₃,^{4a} 1.823(4) Å (for Al-N(SiMe₃)₂). Shorter Al-N distances are found in tricoordinate Al/tricoordinate N structures, for example, monomeric Al[N(SiMe₃)₂]₃, 1.78(2) Å,^{2g} or six-membered planar ring [MeAlN(2,6-iPr₂C₆H₃)]₃, 1.782(4) Å,^{8b} but in the extremely congested monomeric t-Bu₂AlN(SiPh₃)₂ this distance is 1.880(4) Å.8c On the other hand, in tetracoordinate Al/tetracoordinate N ring or cluster structures these lengths typically span the 1.9 to 2.0 Å range, for example, as in cubane (PhAlNPh)₄, 1.914(5) Å,^{8d} dimer [(Me₃Si)₂AlNH₂]₂, 1.955 Å, ^{8e} and trimer (t-Bu₂AlNH₂)₃, 2.008 Å, ^{8f} although in the dimer {[(Me₃Si)₂N]₂AlNH₂}₂ this bond length is much shorter, 1.841 Å (av).^{8g} These trends are illustrated by the structure of (Me₃Si)₂N(Me₂N)Al(μ-NMe₂)₂Al(H)N(SiMe₃)₂ (2) (vide infra) that contains Al atoms connected to both tricoordinate N atoms (terminal congested N(SiMe₃)₂ and noncongested NMe₂) and tetracoordinate N atoms (bridging NMe₂).

The Al-H distance of 1.727(1) Å in 1 is one of the longest among similar symmetrical Al-H bridging distances, possibly indicating a loose association of the monomers in the solid state. However, this can not be reconciled in a straightforward way with the dimer parent ion in the gas phase detected by mass spectrometry. This distance can be compared with the average Al-H lengths in the previously discussed symmetrical dimer [HAl(tmp)₂]₂, 1.68 Å or trimer (t-Bu₂AlH)₃, 1.726(5) Å.^{9a} For the unsymmetrically H-bridged dimer of the [H₃Al•L]₂ type of alane adducts,

[H₃Al•N(Me₂)CH₂CH₂CH₂Cl]₂, the following Al–H distances are found that span almost the entire range of observable distances of this type, namely, two different ring distances, 1.84(3) Å and 1.99(5) Å, and two different terminal distances, 1.20(7) Å and 1.40(6) Å.⁹b Of particular interest also is the average Al–Al distance of 2.661 Å. It can be compared with this separation in other symmetrical dimers such as (HAlMe₂)₂, 2.62 Å⁹c and [HAl(tmp)₂]₂, 2.680(2) Å. More importantly, this distance is in the range of the Al–Al bonding distances in structurally authenticated, neutral, monomeric dialanes [(Me₃Si)₂CH]₄Al₂, 2.660(1) Å⁹d and [(i-Pr₃C₆H₂)]₄Al₂, 2.647(3) Å⁹e or tetrameric cluster [Al(C₅Me₅)]₄, 2.769 Å (av).⁹f Based on that, some bonding interaction along the Al–Al axis is thus probable in 1.

A 1:1 ratio reaction of 1 and HNMe₂ was performed to test preferences of the two possibly competing reactions, namely, aminolysis at the Al–H site with the formation of dihydrogen and transamination at the Al–N(SiMe₃)₂ site(s) with the formation of HN(SiMe₃)₂. These types of reactions were observed to occur simultaneously in the combination of [H₂AlN(SiMe₃)₂]·NMe₃ and NH₃, and yielded a rare benzene soluble polymeric precursor that was used to make transparent AlN coatings on alumina substrates.^{3b} Surprisingly, only minute quantities of H₂ were measured several hours past addition indicating very slow aminolysis. This was further supported by an IR spectrum for raw products that showed a N–H stretching band at 3310 cm⁻¹ consistent with coordinated HNMe₂ by 1 at this stage of reaction. The NMR spectra for the reaction mixture were run in the course of several weeks following addition and showed a multitude of slowly formed products. This was accompanied by increased quantities of evolved H₂ (sharp ¹H NMR resonance at δ 4.51¹⁰) and HN(SiMe₃)₂ consistent with a relatively slow aminolysis and transamination in the system, respectively.

Compound 2 was isolated in small quantities after several days of a low temperature storage of the reaction mixture accompanied by a slow evaporation of volatiles. The NMR data obtained for a fresh solution of 2 in toluene-d₈ were complex and subject to changes

with time. These changes might be indicative of slow equilibration processes and formation of more stable symmetrical products in the solution but, also, of some on-going chemical interactions. Interestingly, the IR spectrum for the freshly isolated product showed only a single, well defined but, alas, broad band in the $\nu(Al-H)$ range at 1860 cm⁻¹.

The molecular structure of 2 is shown in Figure 2. It features a puckered {Al-N-Al-N} ring with unsymmetrical (different) ligands on the aluminum atoms, and can be visualized as a Me₂N-bridged, two-site adduct of the different monomeric aminoalanes Al(NMe₂)₂[N(SiMe₃)₂] and HAl(NMe₂)[N(SiMe₃)₂]. The N(SiMe₃)₂ groups on two different Al ring atoms are in the *cis* position to each other. Potentially increased steric congestion due to the *cis* configuration is apparently counterbalanced by ring puckering, which has the effect of moving apart the N(SiMe₃)₂ groups on the congested side of the ring and getting the neighboring small H and NMe₂ ligands closer on the other side of the ring with a concurrent decrease of the Al-Al distance. The latter distance of 2.829(3) Å seems to be, however, outside the range of any significant aluminum-aluminum bonding interaction (*vide supra*). The ring puckering as defined by the angle between the N(1)-Al(1)-N(2) and N(1)-Al(2)-N(2) planes amounts to 25.5°. The N and Al atoms in the ring are four-coordinated; although the hydrogen atom is not resolved on Al(1), its presence is supported by both structural (pyramidal Al(1) atom) and chemical evidence (IR band in the v(Al-H) range at 1860 cm⁻¹).

Despite the relatively high values of the residuals for 2, the quality of the numerical data is good enough to address some of the molecule's structural aspects. The aluminum-nitrogen bonds in 2 represent a comprehensive range of bond configurations including ring and different exocyclic bonds, all in one molecule. The average Al–N distance in the ring (Al–endo–NMe₂), 1.972 Å, can be compared with the average distances of this type in some of the Me₂N-bridged dimers such as [Al(NMe₂)₃]₂, 1.965 Å^{2e} (or 1.970 Å^{2d}) and [HAl(NMe₂)₂]₂, 1.966 Å^{2d} or trimer (H₂AlNMe₂)₃, 1.950 Å.^{2d} The Al–exo–NMe₂ distance of 1.782(8) Å in 2 belongs, in general, to very short Al–N bond lengths. For

example, the following Al–exo–NMe₂ distances are found in the dimers [Al(NMe₂)₃]₂, 1.800 Å (av)^{2f} (or 1.814 Å (av)^{2d}), [HAl(NMe₂)₂]₂, 1.804(2) Å,^{2d} and [(Me₂N)₂Al{ μ -N(H)1-Adamantanyl}]₂, 1.793 Å^{2f} while the apparently shortest to-date Al–N bond lengths are reported for monomeric Al[N(SiMe₃)₂]₃, 1.78(2) Å,^{2g} and six-membered planar ring [MeAlN(2,6-iPr₂C₆H₃)]₃, 1.782(4) Å.^{8b} The other exocyclic AlN distance(s) in **2**, i.e. Al–exo–N(SiMe₃)₂, 1.839 Å (av), falls well within the range of similar terminal bonds. This is exemplified by comparison of this distance with the respective average lengths in **1**, 1.824 Å, {[(Me₃Si)₂N]₂AlNH₂}₂, 1.841 Å,⁸g or {[(Me₃Si)₂N]₂Al(NH₂)₂}₃Al, 1.850 Å.^{8g} The Al–exo–N(SiMe₃)₂ lengths are generally longer than the Al–exo–NMe₂ lengths and this may reflect the congestion effect of the bulkier N(SiMe₃)₂ group.

In summary, the structure of 2 illustrates the occurrence of both the aminolysis (absence of H on one of the Al atoms) and transamination (singular $N(SiMe_2)_2$ groups on each Al atom) taking place in the reaction between 1 and HNMe₂. Similar combinations of $[H_2AlN(SiMe_3)_2] \cdot NMe_3$ and NH_3 were also reported to proceed *via* concerted ammonolysis and transamination and resulted in a soluble polymeric precursor to aluminum nitride. The data presented here are consistent with complex elimination chemistry in these systems and suggest that the new $\{[(Me_3Si)_2N]_2Al(\mu-H)\}_2$ may be a valuable precursor for conversion to aluminum nitride materials.

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Table 1. Crystallographic Data and Measurements for 1 and 2.

	1	2
molecular formula	C ₂₄ H ₇₄ Al ₂ N ₄ Si ₈	C ₁₈ H ₅₅ Al ₂ N ₅ Si ₄
formula weight	697.55	507.99
crystal system	monoclinic	monoclinic
space group	P2 ₁	P2 ₁ /n
a, Å	13.7119(2)	9.1715(5)
b, Å	18.3400(3)	22.9239(13)
c, Å	17.8971(4)	15.0291(9)
β, deg	91.4750(9)	96.088(2)
v, å3	4499.20(18)	3139.9(3)
Z	4	4
μ, mm ⁻¹	0.297	0.260
temp, K	223(2)	198(2)
D _{calcd} , g/cm ³	1.030	1.075
crystal dimensions, mm	0.10 x 0.10 x 0.10	0.40 x 0.35 x 0.25
Θ range for data collection (deg)	1.14-28.21	1.63-22.50
no. of rflns collected	29387	7735
independent rflns	$17056 (R_{int} = 0.0584)$	$3809 \ (R_{\rm int} = 0.1028)$
data/restraints/parameters	17056/9/697	3499/5/266
R ($I > 2\sigma(I)$); a wR2b	0.0596; 0.1136	0.1220; 0.2918
R (all data); ^a wR2 ^b	0.1110; 0.1356	0.1708; 0.3411
goodness-of-fit ^c	1.027	0.975
final max/min $\Delta \rho$, e/Å ⁻³	0.320/-0.337	0.774/-0.923

 $^{{}^}a\,R = \sum\!\!\Delta\!/\sum(F_o),\, \Delta = |F_o| - |F_c|;\, {}^b\,\,wR2 = \sum[w(F_o{}^2 - F_c{}^2)^2]/\sum[(wF_o{}^2)^2]^{1/2}$

[°] GooF = $[\sum [\mathbf{w}(|F_o| - |F_c|)^2]/(n-p)]^{1/2}$

Table 2. Selected Bond Distances (Å) and Angles (°) for 1 and 2 with Estimated Standard Deviations in Parentheses

	Bond 1	Lengths	
1		2	
Al-exo-N (av)	1.824	Al(1)-exo-N(3)	1.836(4)
Al-exo-N; min/max	1.811(4)/1.844(4)	Al(2)-exo-N(5)	1.842(4)
		Al(2)-exo-N(4)	1.782(8)
		Al(1)-endo-N(2)	1.966(8)
		Al(1)-endo-N(1);	1.948(7)
		Al(2)-endo-N(1)	1.985(8)
		Al(2)-endo-N(2)	1.987(7)
Al-endo-H	1.727(1)	Al-exo-H (assumed)	1.50
Al-Al (av)	2.661	Al(1)-Al(2)	2.829(3)
Si-N (av)	1.755	Si-N (av)	1.743
Si-N; min/max	1.749(5)/1.765(5)	Si-N; min/max	1.7426(10)/1.7430(10)
Si-C (av)	1.874	Si-C (av)	1.87
Si-C; min/max	1.850(7)/1.900(6)	Si-C; min/max	1.834(14)/1.889(10)
		Bond Angles	
1		2	
N-Al-N (av)	124.6	N(1)-Al(1)-N(2)	86.1(3)
N-Al-N; min/max	124.2(2)/125.1(2)	N(1)-Al(2)-N(2)	84.5(3)
N-Al-Al (av)	117.7	Al(1)-N(1)-Al(2)	92.0(3)
N-Al-Al; min/max	115.19(14)/120.5(2)	Al(1)-N(2)-Al(2)	91.4(3)
Si(2)-N(1)-Al(1)	115.0(2)	N(3)-Al(1)-N(1)	116.4(3)
Si(1)-N(1)-Al(1)	125.9(3)	N(3)-Al(1)-N(2)	122.4(3)
Si(2)-N(1)-Si(1)	118.7(2)	N(4)-Al(2)-N(5)	111.3(3)

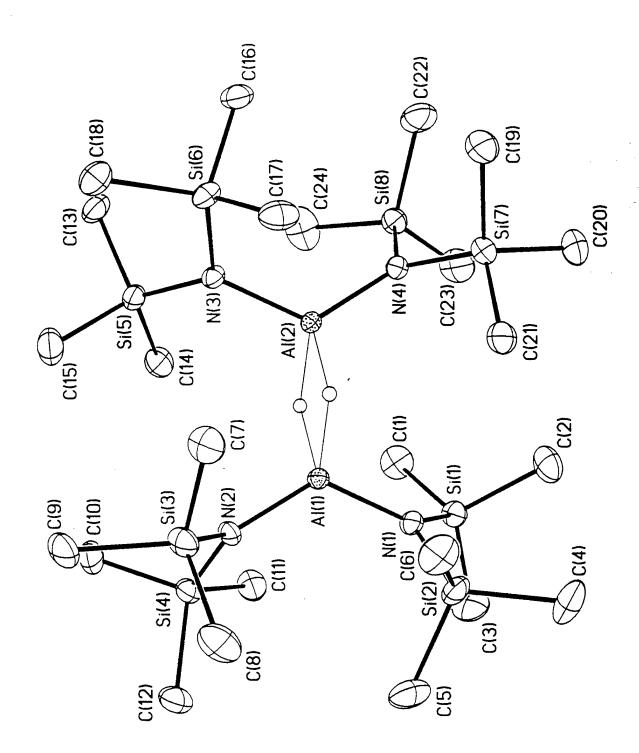
Table 2, continued

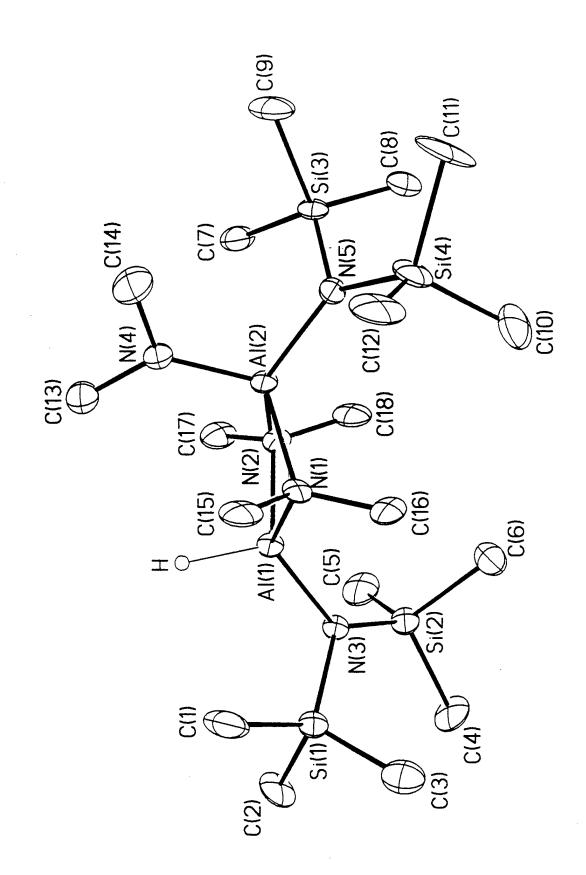
Bond Angles		
1	2	
	N(4)-Al(2)-N(1)	110.2(4)
	N(4)-AI(2)-N(2)	114.0(4)
	N(5)-Al(2)-N(2)	114.9(4)
	N(5)-Al(2)-N(1)	119.5(3)

Captions for Figures

Figure 1. Thermal ellipsoid diagram (30% probability ellipsoids) showing the molecular structure of 1 (independent molecule 1). All C-hydrogen atoms are omitted for clarity.

Figure 2. Thermal ellipsoid diagram (30% probability ellipsoids) showing the molecular structure of 2. All C-hydrogen atoms are omitted for clarity.





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